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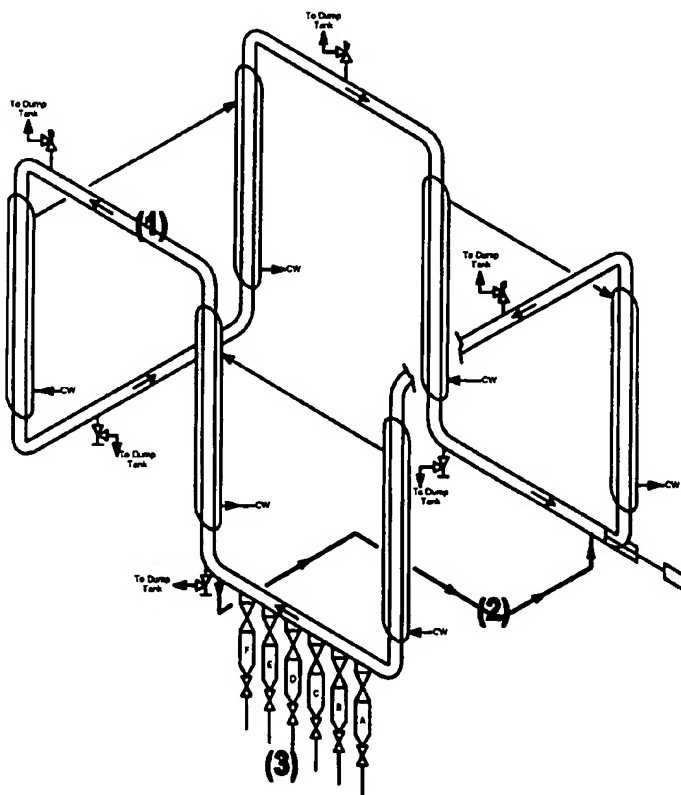
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(54) Title: **SLURRY LOOP POLYOLEFIN REACTOR**



(57) **Abstract:** The present invention discloses a slurry loop reactor comprising one or more loops, capable of improving the properties of the product by enhanced homogeneity of the circulating slurry.

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